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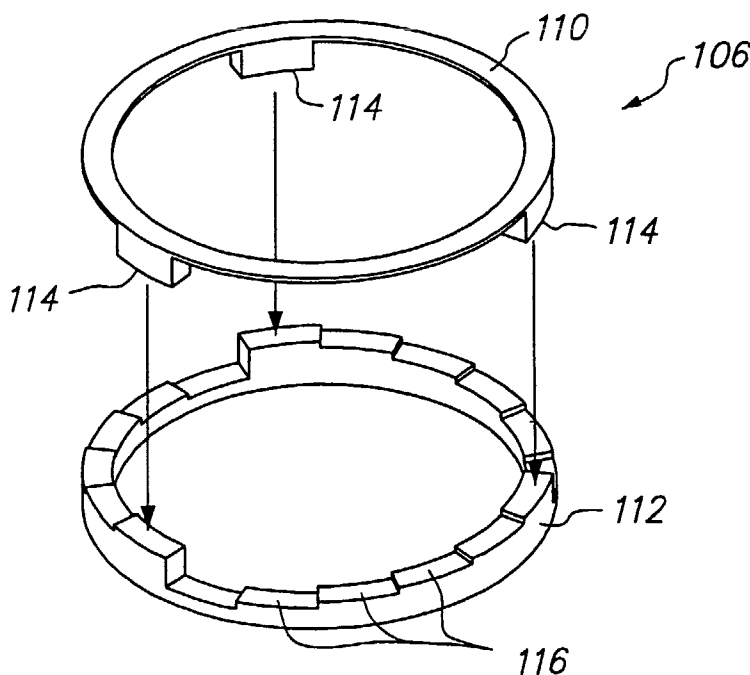
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(54) Title: PLASMA APPARATUS WITH DEVICE FOR REDUCING POLYMER DEPOSITION ON A SUBSTRATE AND METHOD FOR REDUCING POLYMER DEPOSITION



(57) Abstract: An adjustable RF coupling ring is capable of reducing a vertical gap between a substrate and a hot edge ring in a vacuum processing chamber. The reduction of the gap reduces polymer deposits on the substrate and electrostatic chuck and improves wafer processing.

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